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PATENT
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Gurtej Singh Sandhu et al.

Examiner: Unknown

Serial No.: Unknown

Group Art Unit: Unknown

Filed: Herewith

Docket: 303.676US2

Title: CHEMICAL VAPOR DEPOSITION OF TITANIUM

PRELIMINARY AMENDMENT

Commissioner for Patents
Washington, D.C. 20231

When the above-identified patent application is taken up for consideration, please amend the application as follows:

IN THE SPECIFICATION

Please make the paragraph substitutions indicated in the appendix entitled Clean Version of Amended Specification Paragraph. The specific changes incorporated in the substitute paragraph are shown in the following marked-up version of the original paragraph:

The paragraph beginning on page 1, line 4 is amended as follows:

This application is a Divisional of U.S. Application No. 09/489,187, filed on January 20, 2000, which is a continuation-in-part of U.S. Application Serial No. 09/030,705, filed February 25, 1998, now issued as U.S. Patent 6,143,362 on November 7, 2000, which is hereby incorporated by reference in its entirety.

IN THE CLAIMS

Please cancel claims 1-43 and 46-59 after adding the following new claims.

- Sub B1
A1
60. (New) An integrated circuit comprising:
a semiconductor substrate;
an electronic device coupled to the semiconductor substrate, the electronic device having an active region;
an insulating layer over the active region;
an alloy layer of a titanium alloy within a contact opening in the insulating layer, the